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TITLE: ELECTRO-CHEMICAL DEPOSITION CELL FOR FACE-UP
PROCESSING OF SINGLE SEMICONDUCTOR SUBSTRATES
INVENTOR: DORDI, ET AL.

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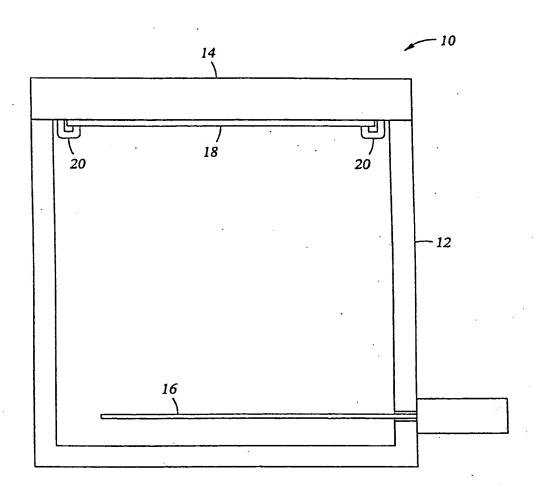
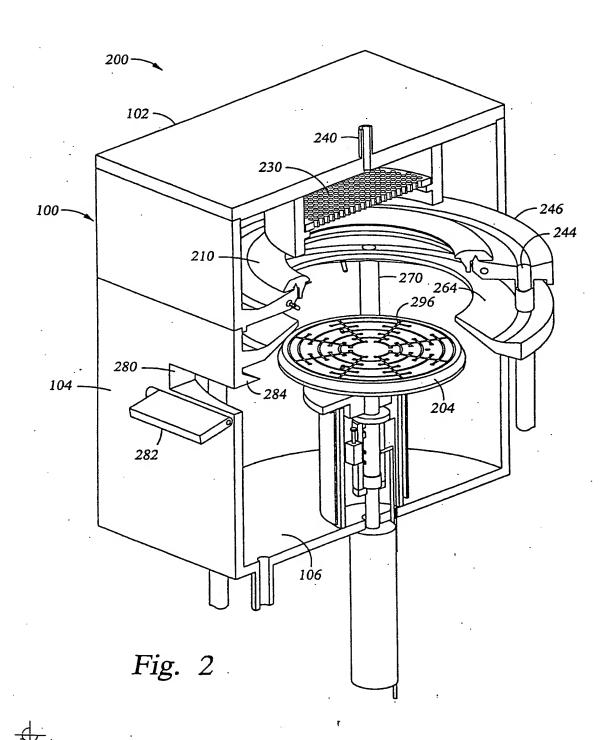


Fig. 1 (PRIOR ART)

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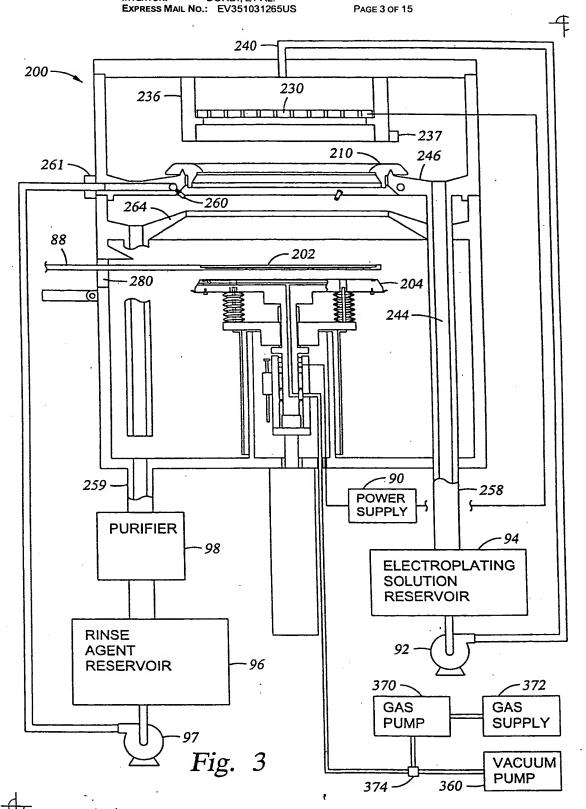
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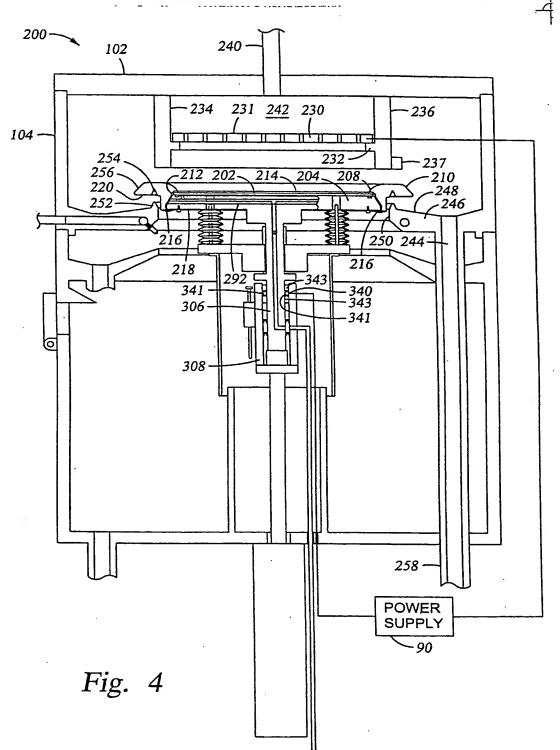
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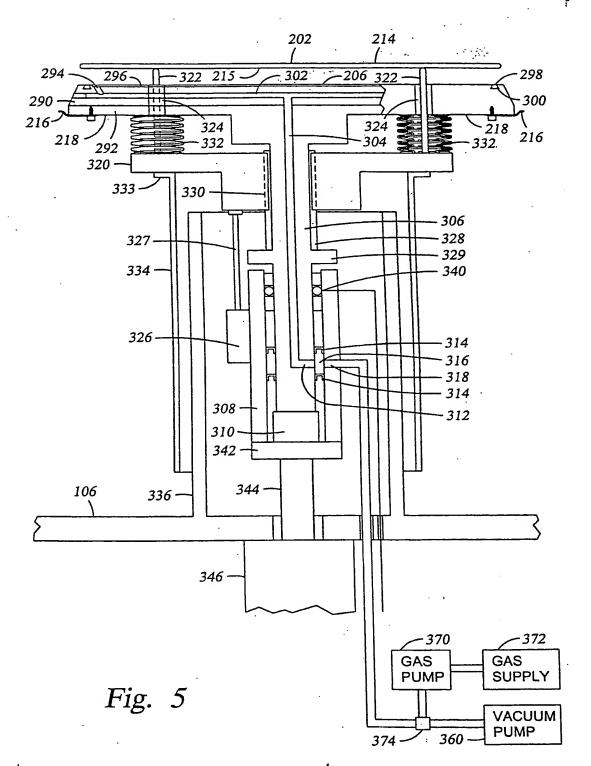


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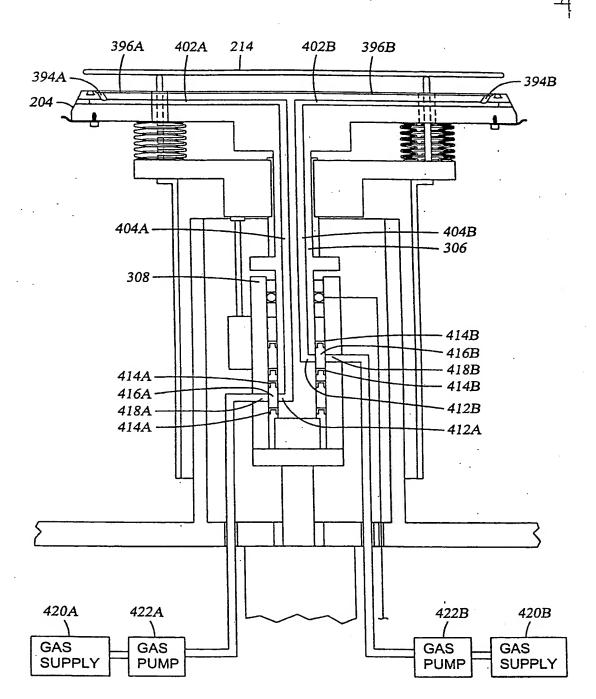
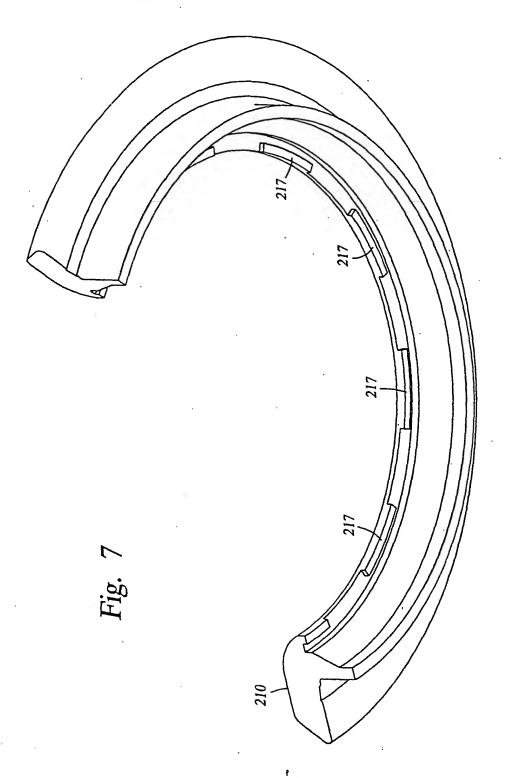
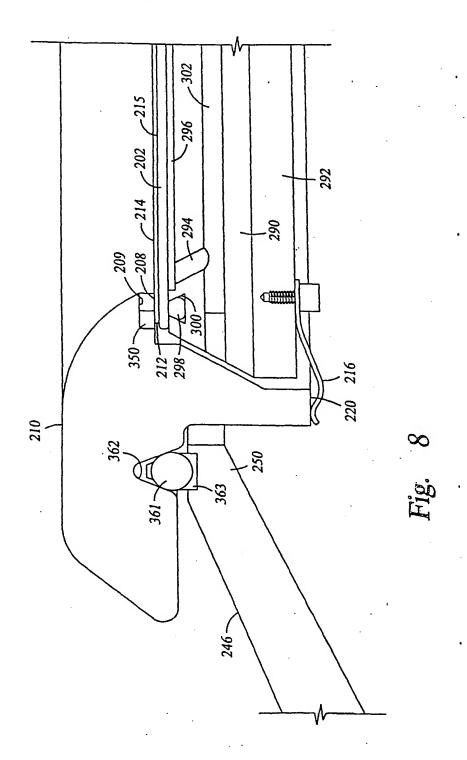


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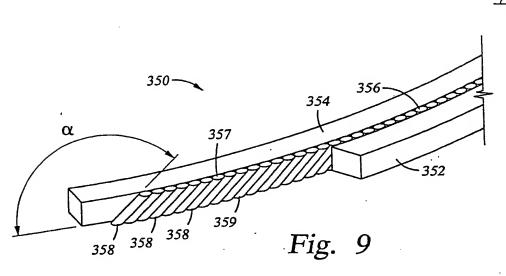
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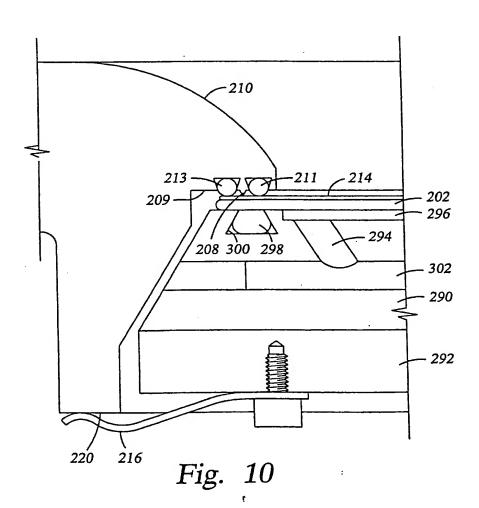


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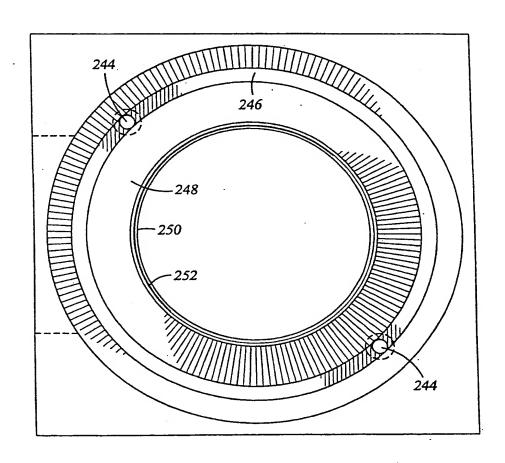
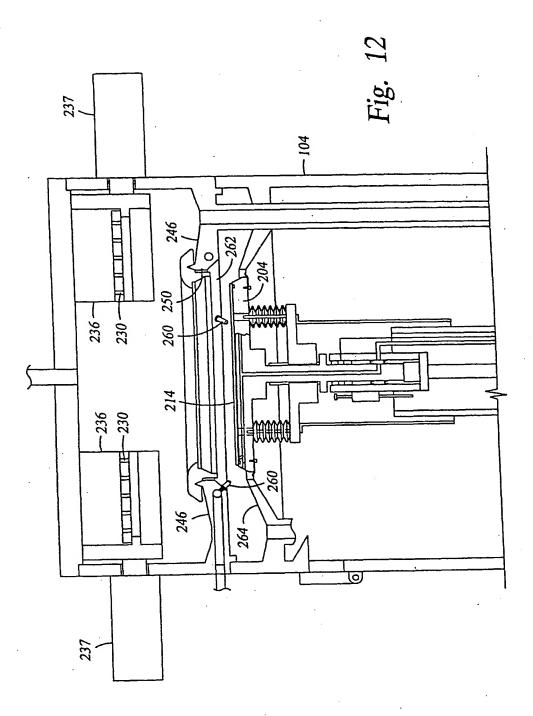
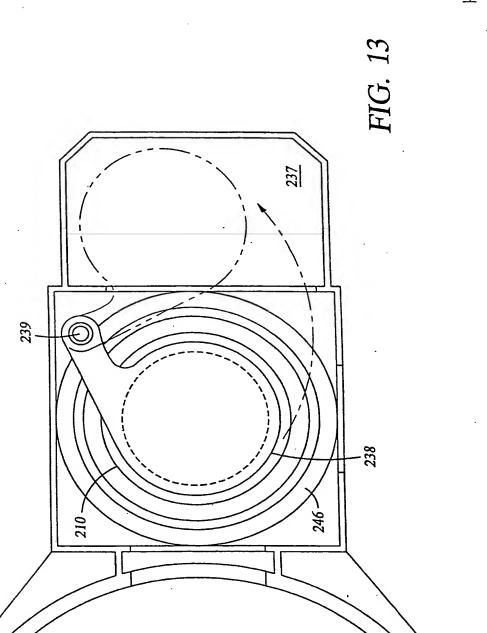


Fig. 11

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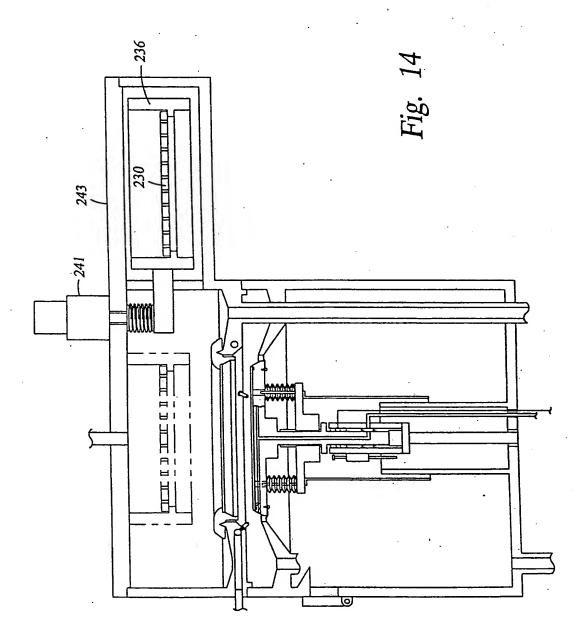


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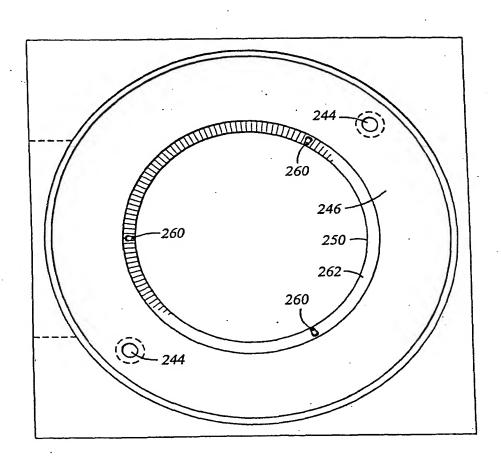


Fig. 15

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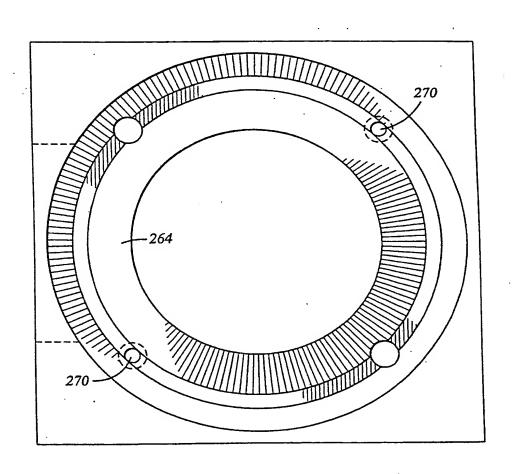


Fig. 16